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9902806-6
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INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification ⁶: G03F 7/033, 7/004, 7/00	A1	(11) International Publication Number: WO 98/55899 (43) International Publication Date: 10 December 1998 (10.12.98)
(21) International Application Number: PCT/EP98/03034 (22) International Filing Date: 22 May 1998 (22.05.98) (30) Priority Data: 1302/97 2 June 1997 (02.06.97) CH (71) Applicant: CIBA SPECIALTY CHEMICALS HOLDING INC. [CH/CH]; Klybeckstrasse 141, CH-4057 Basel (CH). (72) Inventor: MUNK, Kurt; Muttenerstrasse 28, D-79639 Grenzach-Wyhlen (DE).		(81) Designated States: CA, CN, JP, KR, SG, European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE). Published <i>With international search report. Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.</i>
(54) Title: LIQUID PHOTOSENSITIVE COMPOSITION (57) Abstract A photosensitive composition which is liquid at room temperature and which comprises a) 18 to 22 % by weight of a binder polymer based on a styrene-maleic anhydride halfester copolymer, b) 10 to 15 % by weight of at least one photocurable acrylate compound, c) 0.1 to 10 % by weight of a photoinitiator, and d) 45 to 70 % by weight of a propylene glycol halfester or propylene glycol halfether, the sum of the components a) to d) being 100 % by weight, is suitable for the production of photostructured objects, preferably for the production of telephone cards.		